

# GC-MS DW-EXPEC3750

# Gas Chromatography-Quadrupole Mass Spectrometer

#### Introduction

DW-EXPEC3750 is a special-purpose detection and analysis instrument for laboratories based on the basic principle of Gas chromatography mass spectrometry. It adopts the advanced electronic flow pressure control system, microfluidic plate control technology, high-precision independent temperature control system, and high-sensitivity MS detector, meet the user's requirements for the capability, reliability, stability and advanced nature of instrument analysis.



### **Features**

### • Inherit the classic workstation without changing the usage habits

- 1. The workstation software inherits the classic operation interface, allowing the users not to change their usage habits.
- 2. The kernel uses Chinese language, which is specially designed for the Chinese users
- 3. With the batch processing function, the statistical analysis is automatically performed on sample data, to draw sample trend charts

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## • Multiple ion source configurations

- 1. Universal ion sources (EI and CI) are covered and flexible configuration for applications is realized
- 2. SIP high-sensitivity ion source is supported, the transmission lens design is optimized, and the ion transport efficiency is displayed, greatly improving the sensitivity
- 3. Color-coated inert metal material is used, to reduce complex matrix adsorption, and effectively extend the instrument time



# • Durable and highly sensitive detector

- 1. The target ion flow passes through triple off-axis trajectories before reaching the electron multiplier, effectively shielding neutral interference and reducing the baseline noise
- 2. Highly durable electron multiplier effectively reduces the usage cost of mass spectrometer



## **Applications**

Laboratory and vehicle-mounted scenarios:

With the excellent anti-seismic design, the DW-EXPEC3700 is easy to be deployed on the vehicle, free from the impact of bumps on the analysis results.

A vacuum environment can be created in an ultra-efficient manner for immediate measurement after the parking, saving the valuable time.



# **Specifications**

D. 1	
Peak area repeatability	< 0.5%.
Retention time repeatability	< 0.008%.
8-inch high-resolution full-color capacitive touch scr	een.
	roid system, with the graphical interface in Cheese, full touch for operation, t functions such as self-diagnosis reminder, self-leakage detection, etc., for easily grasping of the status of the instrument.
2. Column oven	
Temperature range applicable to all columns and the	eir separation requirements.
Room temperature	Room temperature +4°C-450°C.
Temperature setting accuracy	≤0.1°C.
Supporting 32 oven heating gradients,33 constant terprogrammed temperature rise and programmed rise and	
Maximum hearting rage	≥120°C/min.
Oven cooling rate	6 min from 450°C to 50°C, at a room temperature of 20°C.
Ambient temperature sensitivity	1°C change in ambient temperature, change in column oven average temperature <0.01 °C.
3. Electronic gas circuit control	
Standardized pressure and temperature compensation	on functions.
Electronic pressure control with ruby damping, with	pressure control accuracy at ± 0.001 psi.
Pressure units are available in psi\kPa\bar;	
Programed pressure rise/flow rise	Up to forth order.
Supported carrier and makeup gas types	N <sub>2</sub> , He, H <sub>2</sub> .
Stability of carrier gas flow rate	Less than1%/10 min.
4. Injection port	
Supports installation of up to two injection ports.	
Fully electronic gas circuit control, supporting press	are compensation and temperature compensation.
Injection port type	Standard split/split less injection port, ultra-deactivated split/split less injection port.
Compatible with all capillary columns(inner diamete	er:0.1mm-0.53mm) .
Split ratio up to 12500:1 to avoid column overload.	
Supporting, split ,split less, pulse spilt, pulse split less	s injection and other injection modes.
Maximum operating temperature	450°C.
Temperature setting accuracy	≤0.1°C.
	ee gas consumption without compromising chromatographic separation effects
Electronic septum purge flow control to effectively el	iminate chromatographic ghost peaks.
Flow control range 0-500mL/min(N <sub>2</sub> ),0-1000mL/min	<u> </u>
peak shape and reproducibility of active substances.	ng, eliminating active sites on surface and improving detection sensitivity,
QMS  1. Transfor line	
1. Transfer-line Transfer-line temperature 50-400 °C without cold po	int
I ranster-line temperature 50-400 °C without cold po Ion-source	'HIL.
Dual-filament high efficiency EI source, inert materi	al.
High sensitivity ion source with increased ionization	
Positives/negative CI source.	
Emission	0-300μΑ
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Ion source cleaning gas available with flow ra	
Quadrupole	
High precision Mo quadrupole without tempor	erature control.
Pre-rod used to decrease fringing field effect	and the contamination of the main rod.
Mass range	1.5u-1200u
Mass Resolution	unit mass resolution
Mass Stability	±0.10u/48h
Sensitivity	Inert ion source: 1pg (OFN) , S/N≥1500: 1 SIP: 100 fg (OFN) , S/N≥300: 1 NCI: 200 fg (OFN) , S/N≥2000: 1 PCI: 100 pg (BZP) , S/N≥1200: 1
Side-opening-board design. Maintenance of t	he ion source without the disassembly of the columns.
2. Detector	
Long-life channel EM	
Triaxial ion path detector to decrease the infl	uence of neutrals
Dynamic range	≥10 <sup>7</sup>
3. Vacuum system	
Vacuum system of Mechanical pump and tur	bopump (250L/s of He)